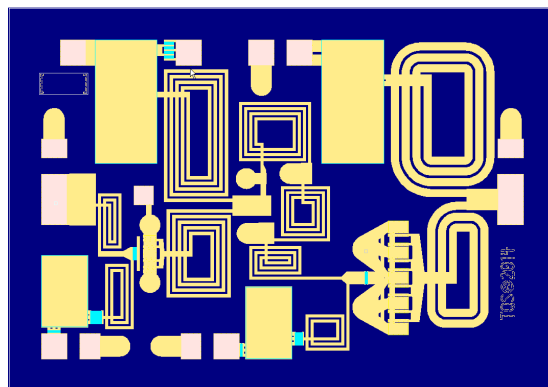


### Applications

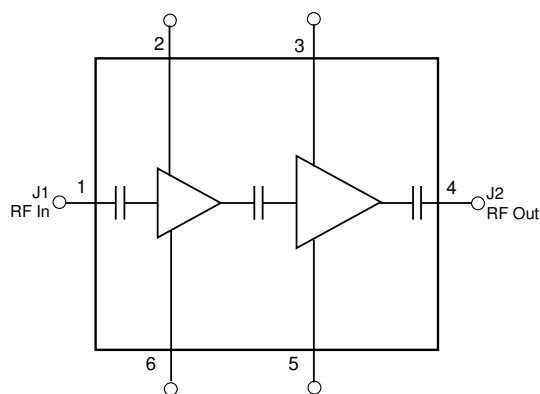
- Commercial and Military Radar
- Communications
- Electronic Warfare (EW)



### Product Features

- Frequency Range: 2-6 GHz
- Output Power: > 31.5 dBm ( $P_{IN} = 18$  dBm)
- PAE: > 31 % ( $P_{IN} = 18$  dBm)
- Large Signal Gain: > 13.5 dB ( $P_{IN} = 18$  dBm)
- Small Signal Gain: > 24 dB
- $V_D = 25$  V,  $I_{DQ} = 40$  mA,  $V_G = -2.5$  V typ.
- Chip Dimensions: 2.140 mm x 1.500 mm x 0.10 mm

### Functional Block Diagram



### General Description

TriQuint's TGA2597 is a driver amplifier fabricated on TriQuint's TQGaN25 0.25um GaN on SiC production process. The TGA2597 operates from 2.0 to 6.0 GHz and provides > 31.5 dBm of output power with > 13.5 dB of large signal gain and > 31 % power-added efficiency.

The TGA2597 operates with the same drain bias as corresponding GaN HPA's making it an ideal driver amplifier. It can also function as the output amplifier in lower power applications. The TGA2597 is internally matched to 50 ohms, and includes integrated DC blocks on both RF ports allowing for simple system integration.

Lead-free and RoHS compliant.

Evaluation boards are available upon request.

### Pad Configuration

Pad No.	Symbol
1	RF In
2	$V_{D1}$
3	$V_{D2}$
4	RF Out
5	$V_{G2}$
6	$V_{G1}$

### Ordering Information

Part	ECCN	Description
TGA2597	EAR99	2-6 GHz GaN Driver Amplifier

### Absolute Maximum Ratings

Parameter	Value
Drain Voltage ( $V_D$ )	40 V
Gate Voltage Range ( $V_G$ )	-8 to 0 V
Drain Current w/ RF Drive ( $I_{D\_DRIVE}$ ):	
1 <sup>st</sup> Stage ( $I_{D1\_DRIVE}$ )	95 mA
2 <sup>nd</sup> Stage ( $I_{D2\_DRIVE}$ )	305 mA
Gate Current ( $I_G$ ):	
1 <sup>st</sup> Stage ( $I_{G1}$ ) (+ $I_{G1}$ @ $T_{CH}=200$ °C)	-0.2 / 1.4 mA
2 <sup>nd</sup> Stage ( $I_{G2}$ ) (+ $I_{G2}$ @ $T_{CH}=200$ °C)	-0.64 / 2.8 mA
Power Dissipation ( $P_{DISS}$ )	5.4 W
Input Power, CW, 50 $\Omega$ ( $P_{IN}$ ) <sup>1</sup>	24 dBm
Input Power, CW, 3:1 VSWR ( $P_{IN}$ ) <sup>1</sup>	24 dBm
Channel temperature ( $T_{CH}$ )	275 °C
Mounting Temperature (30 Seconds maximum)	320 °C
Storage Temperature	-55 to 150 °C
Notes:	
1. $V_D = 25$ V, $I_{DQ} = 40$ mA, $T_{BASE} = 85$ °C	

Operation of this device outside the parameter ranges given above may cause permanent damage. These are stress ratings only, and functional operation of the device at these conditions is not implied.

### Recommended Operating Conditions

Parameter	Value
Drain Voltage ( $V_D$ )	25 V
Drain Current ( $I_{DQ}$ )	40 mA
Drain Current w/ RF Drive ( $I_{D\_DRIVE}$ )	250 mA
Gate Voltage ( $V_G$ ), typ.	-2.5 V

Electrical specifications are measured at specified test conditions. Specifications are not guaranteed over all operating conditions.

### Electrical Specifications

Test conditions unless otherwise noted: 25 °C,  $V_D = 25$  V,  $I_{DQ} = 40$  mA,  $V_G = -2.5$  V typ., die mounted to EVB

Parameter	Min	Typical	Max	Units
Operating Frequency Range	2.0		6.0	GHz
Output Power (@ $P_{in} = 18$ dBm)		> 31.5		dBm
Power Added Efficiency (@ $P_{in} = 18$ dBm)		> 31		%
Small Signal Gain		> 24		dB
Input Return Loss		> 15		dB
Output Return Loss		> 5		dB
IM3 ( $P_{out}/Tone \leq 24$ dBm, 10 MHz tone spacing)		< -25		dBc
Small Signal Gain Temperature Coefficient		-0.050		dB/°C
Output Power Temperature Coefficient		-0.001		dB/°C

### Thermal and Reliability Information

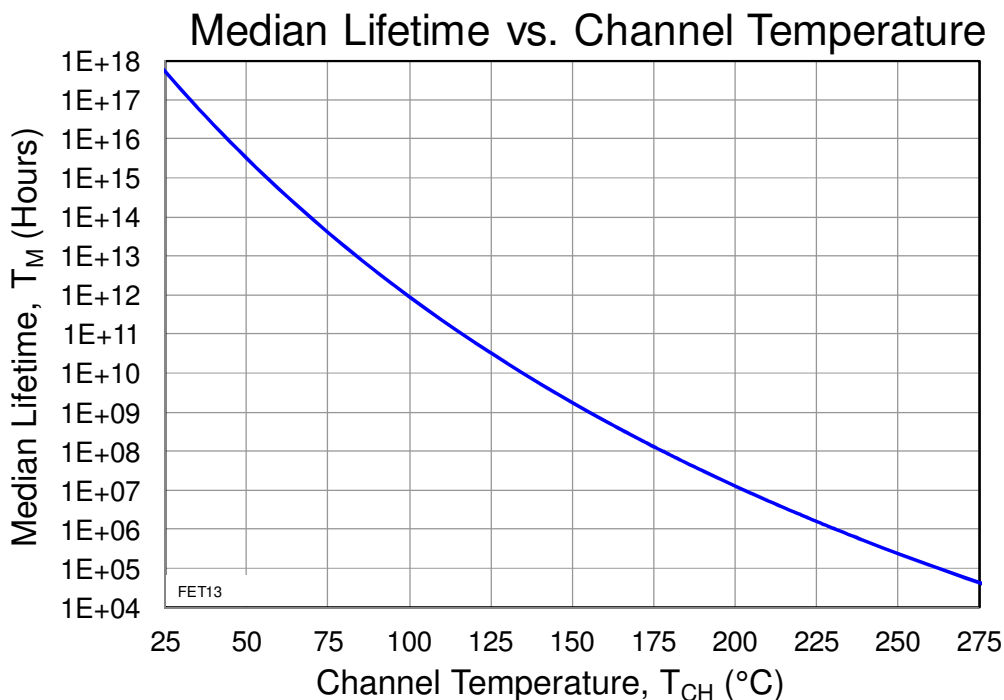
Parameter	Test Conditions	Value	Units
Thermal Resistance ( $\theta_{JC}$ ) <sup>(1)</sup>	$T_{PKG} = 85^\circ\text{C}$ , $V_D = 25\text{ V}$ , $I_{DQ} = 40\text{ mA}$ , $I_{D\_DRIVE} = 208\text{ mA}$ , $P_{IN} = 18\text{ dBm}$ , $P_{OUT} =$ $32.5\text{ dBm}$ , $P_{DISS} = 3.5\text{ W}$	17.14	$^\circ\text{C/W}$
Channel Temperature ( $T_{CH}$ )		145	$^\circ\text{C}$
Median Lifetime ( $T_M$ )		3.07E09	Hrs

Notes:

- MMIC soldered to 40 mil thick Cu-Mo carrier plate using 1.5 mil thick AuSn solder. Thermal resistance is determined from the channel to the back of the carrier plate (fixed  $85^\circ\text{C}$  temp.).

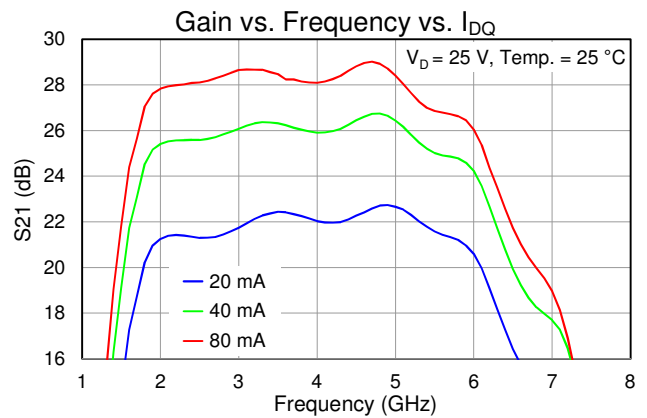
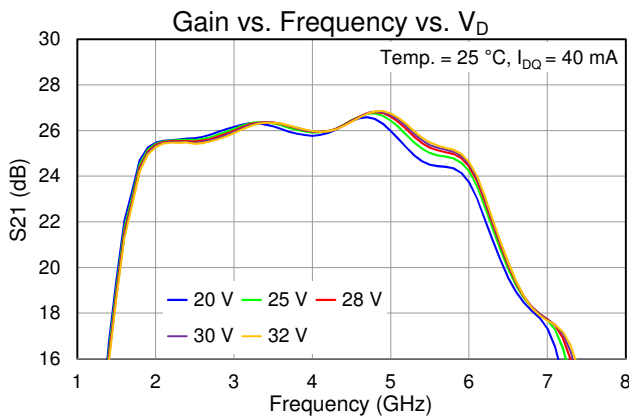
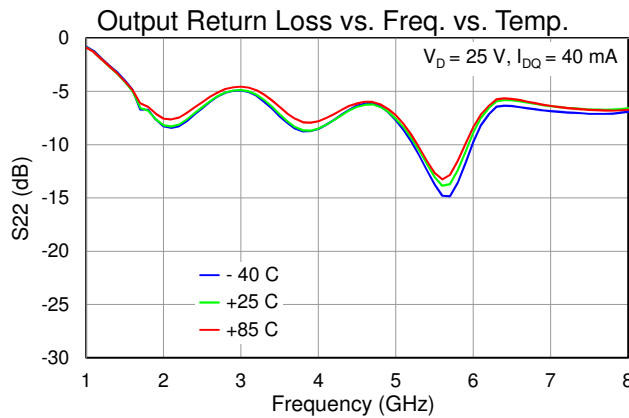
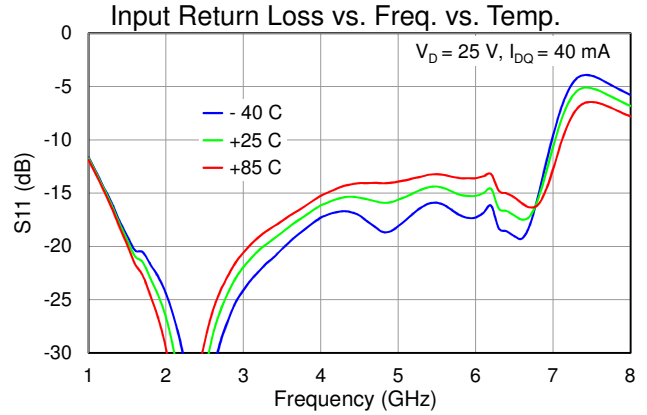
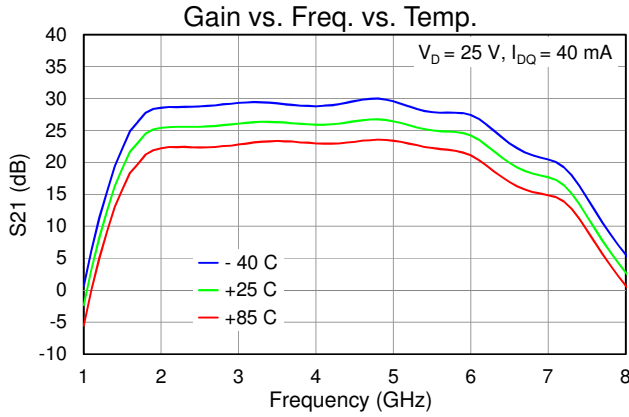
### Median Lifetime

Test Conditions: 40 V; Failure Criteria = 10% reduction in  $I_{D\_MAX}$



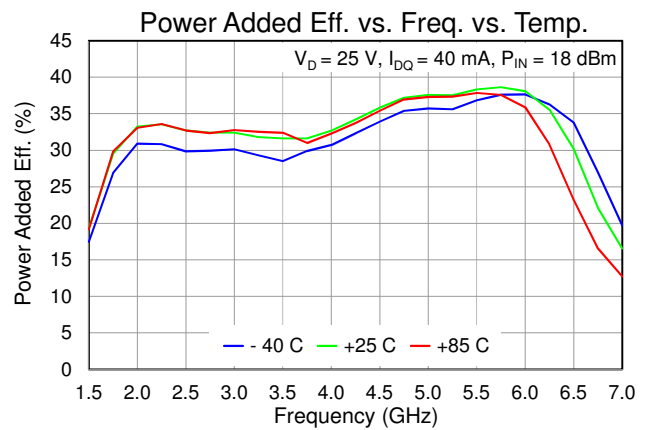
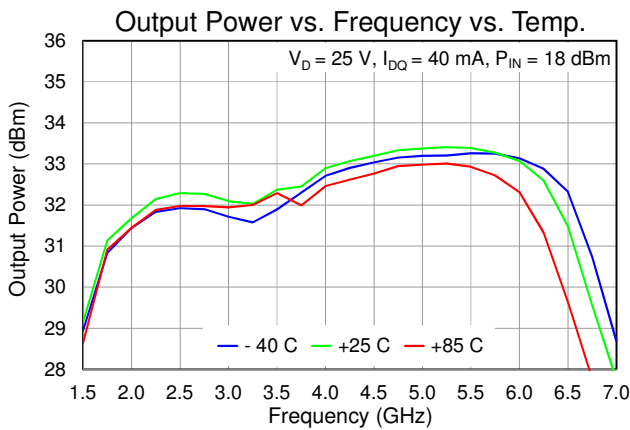
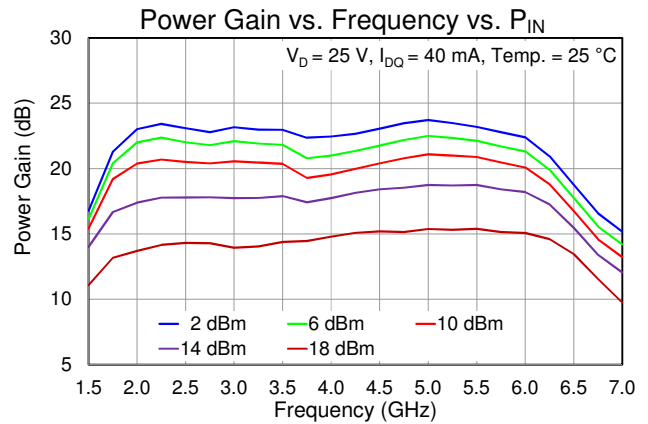
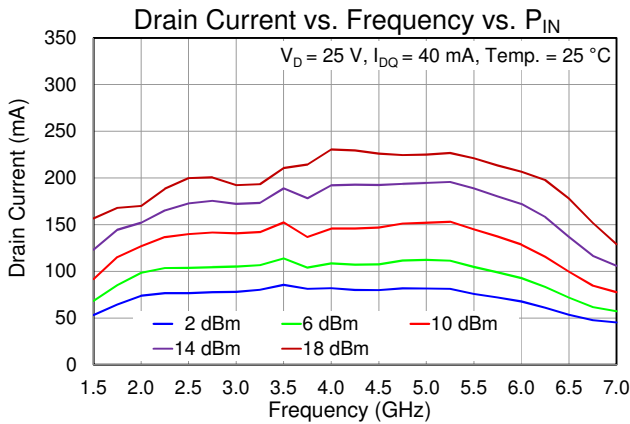
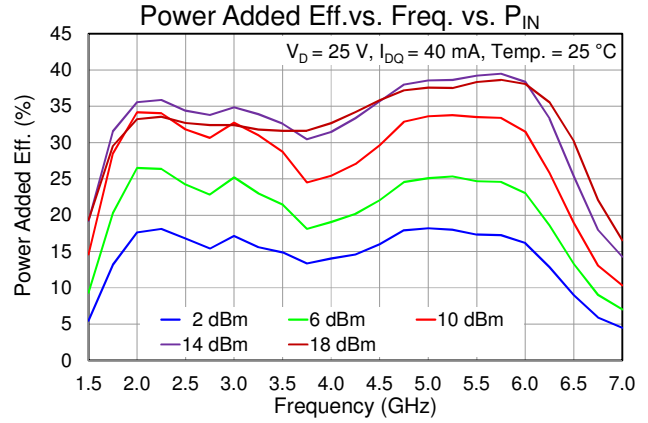
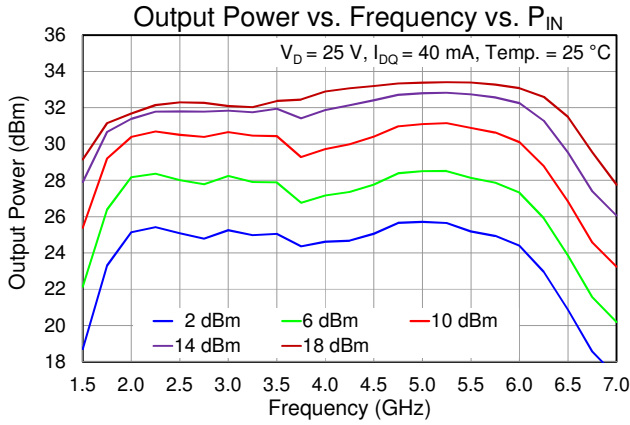
### Typical Performance – Small Signal

Test conditions unless otherwise noted: 25 °C,  $V_D = 25\text{ V}$ ,  $I_{DQ} = 40\text{ mA}$ ,  $V_G = -2.5\text{ V typ.}$ , die mounted to EVB



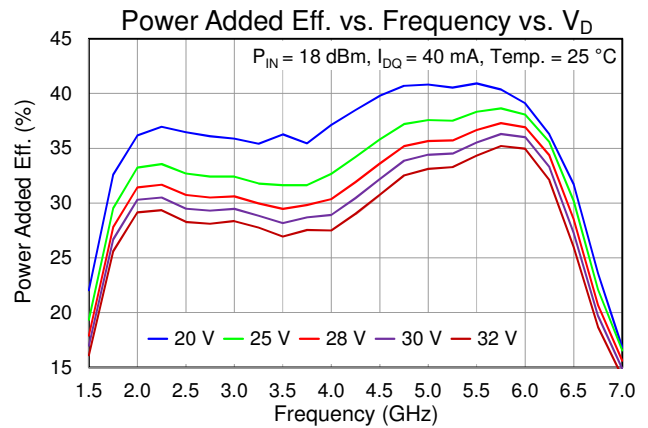
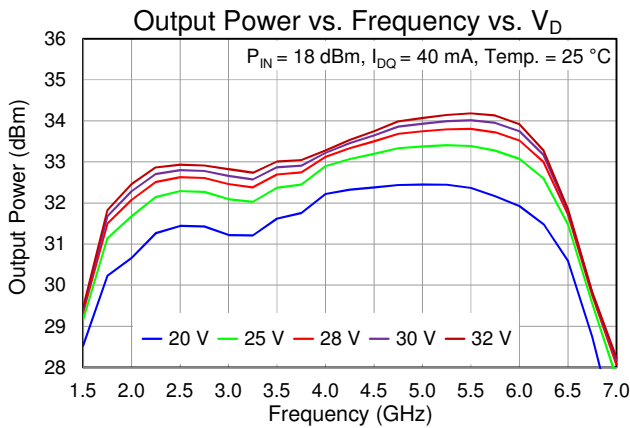
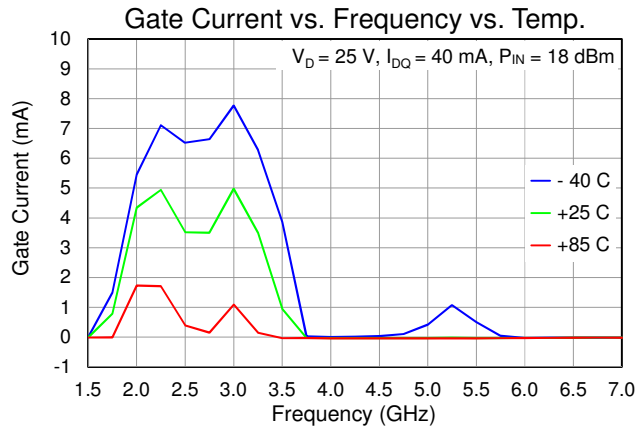
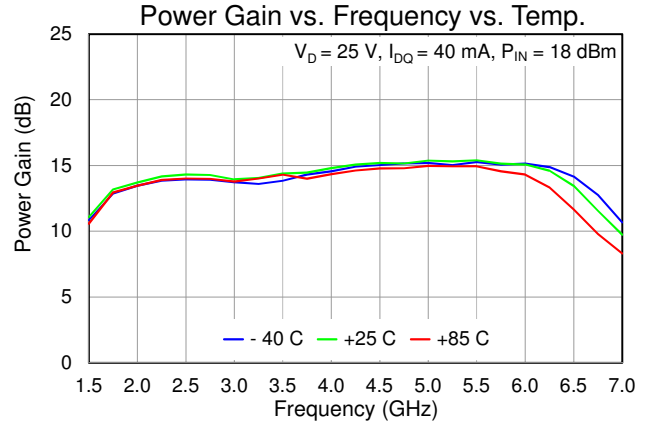
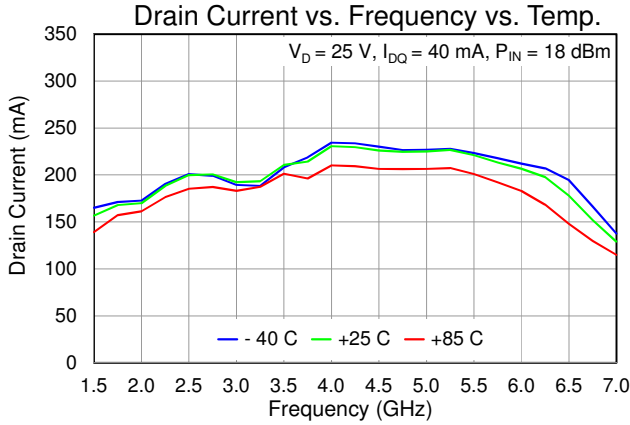
### Typical Performance – Large Signal

Test conditions unless otherwise noted: 25 °C,  $V_D = 25$  V,  $I_{DQ} = 40$  mA,  $V_G = -2.5$  V typ., die mounted to EVB



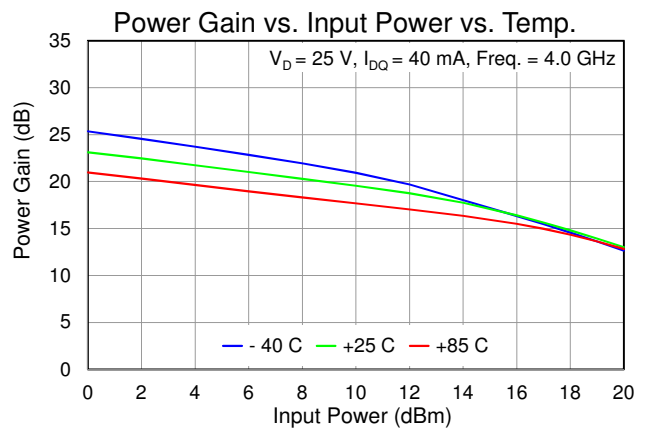
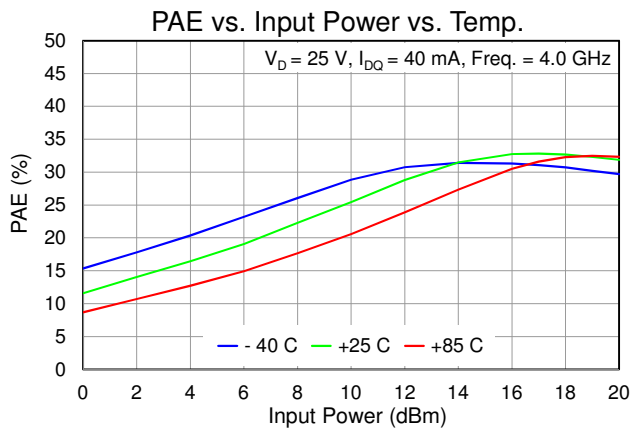
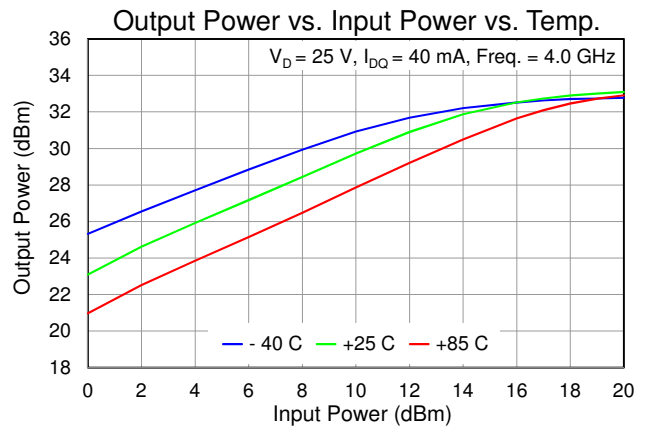
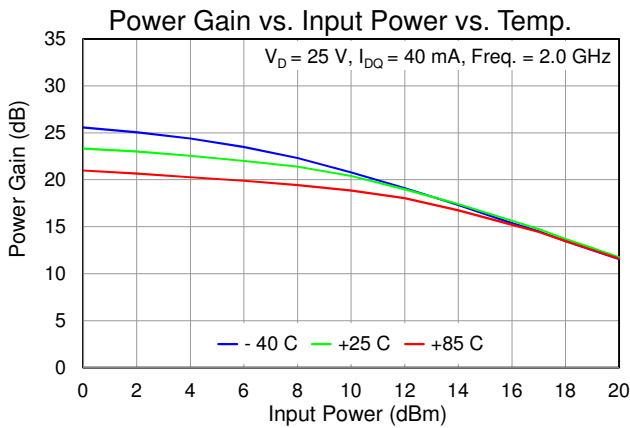
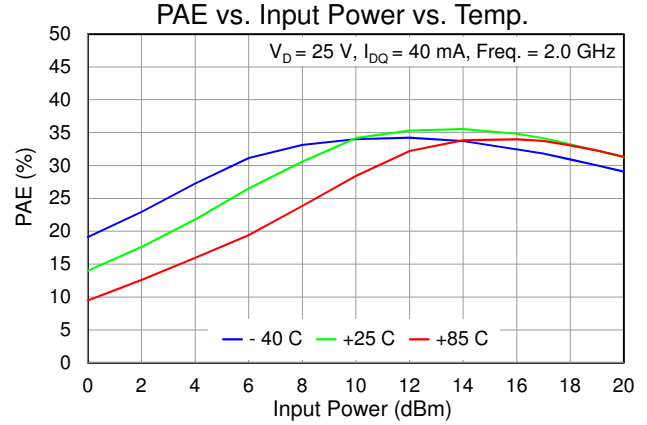
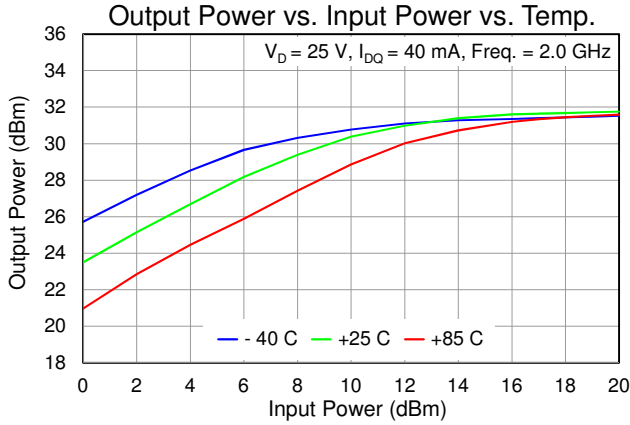
### Typical Performance – Large Signal

Test conditions unless otherwise noted: 25 °C,  $V_D = 25$  V,  $I_{DQ} = 40$  mA,  $V_G = -2.5$  V typ., die mounted to EVB



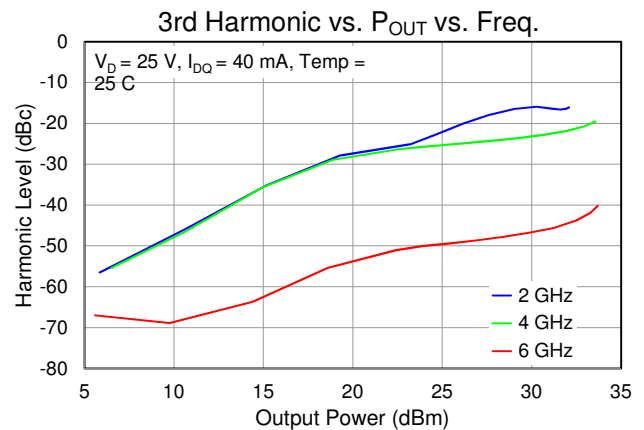
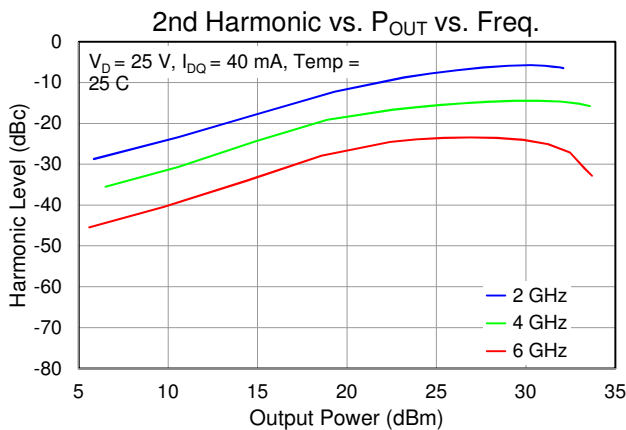
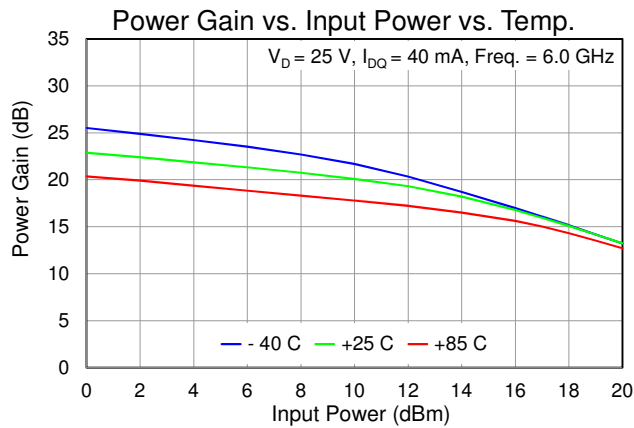
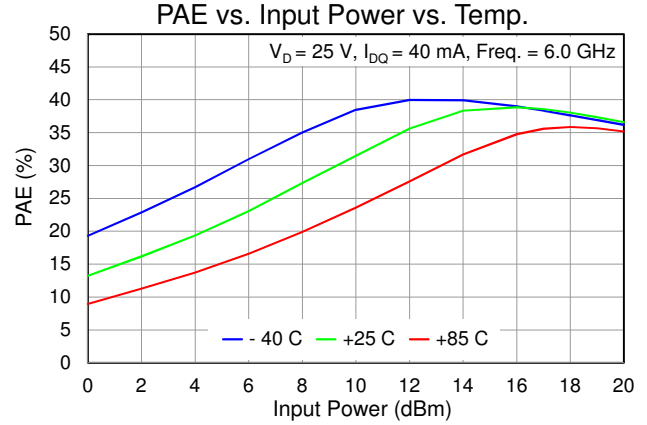
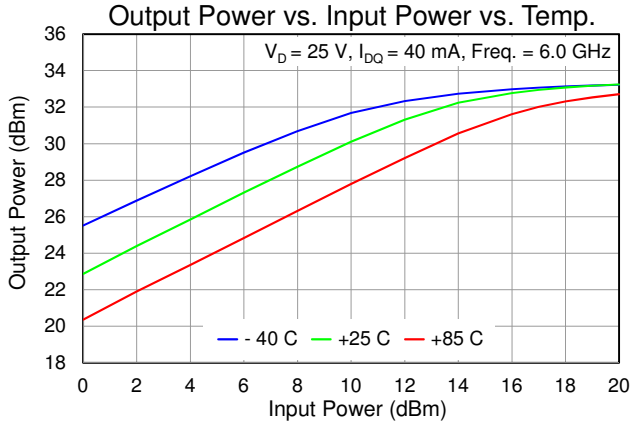
**Typical Performance – Large Signal**

Test conditions unless otherwise noted: 25 °C,  $V_D = 25\text{ V}$ ,  $I_{DQ} = 40\text{ mA}$ ,  $V_G = -2.5\text{ V typ.}$ , die mounted to EVB



### Typical Performance – Large Signal, Harmonics

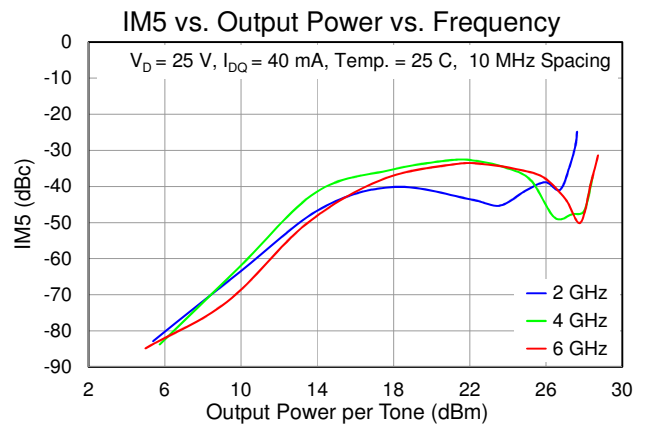
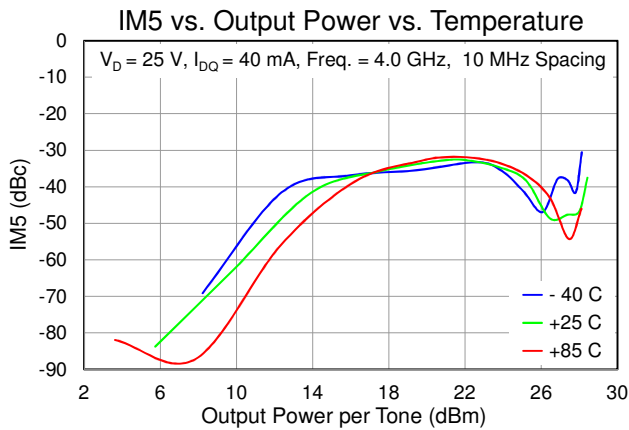
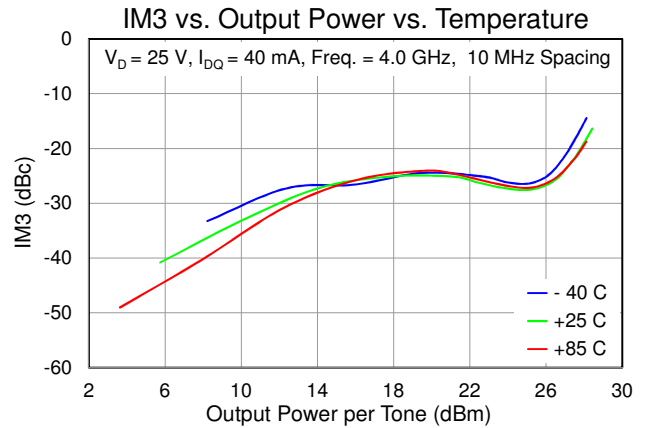
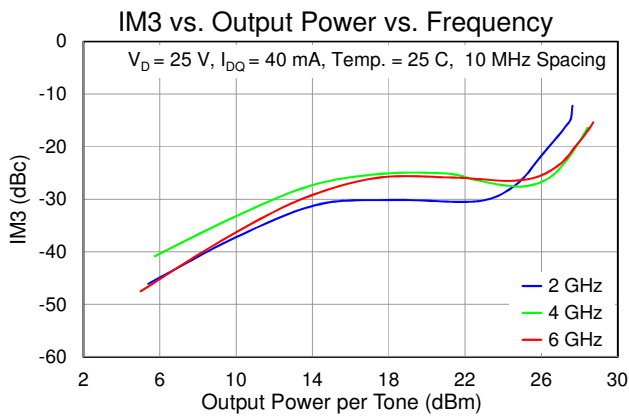
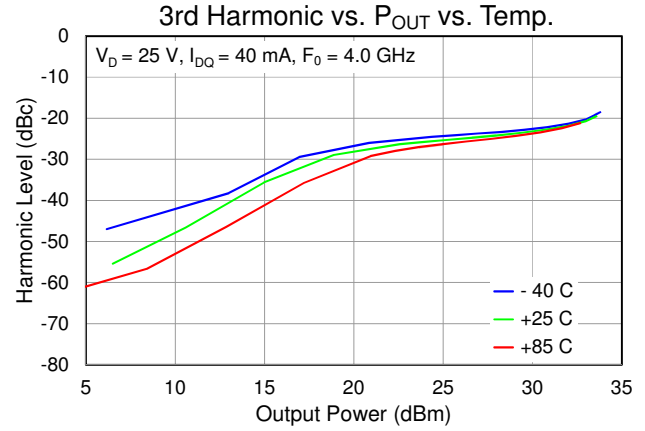
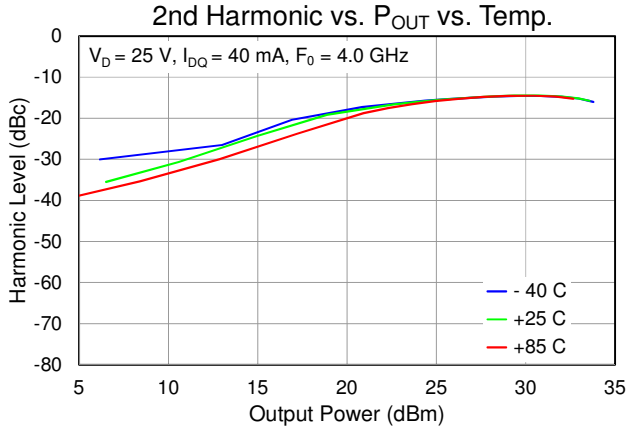
Test conditions unless otherwise noted: 25 °C,  $V_D = 25\text{ V}$ ,  $I_{DQ} = 40\text{ mA}$ ,  $V_G = -2.5\text{ V typ.}$ , die mounted to EVB



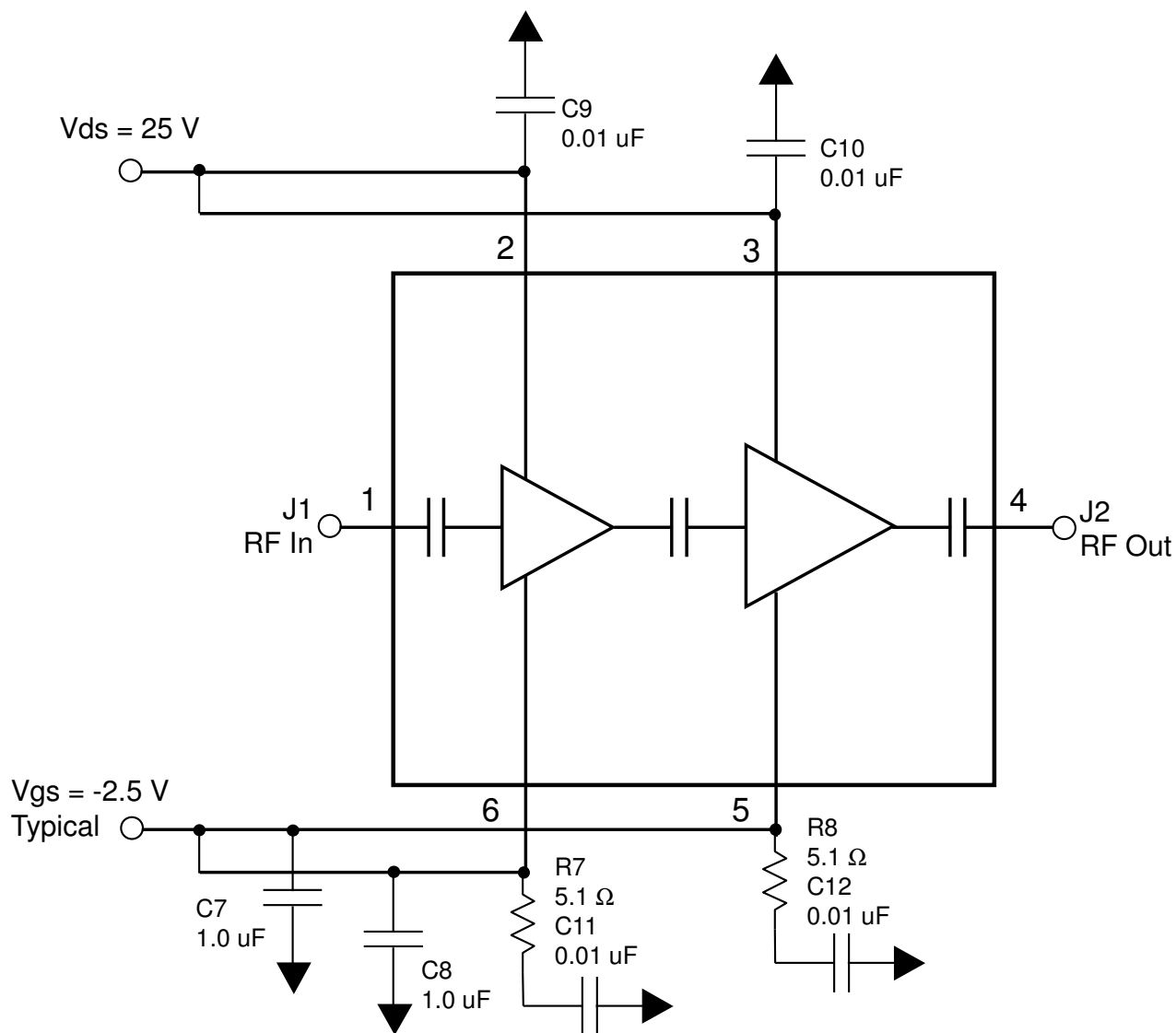


### Typical Performance – Harmonics, Linearity

Test conditions unless otherwise noted: 25 °C,  $V_D = 25$  V,  $I_{DQ} = 40$  mA,  $V_G = -2.5$  V typ., die mounted to EVB



**Application Circuit**



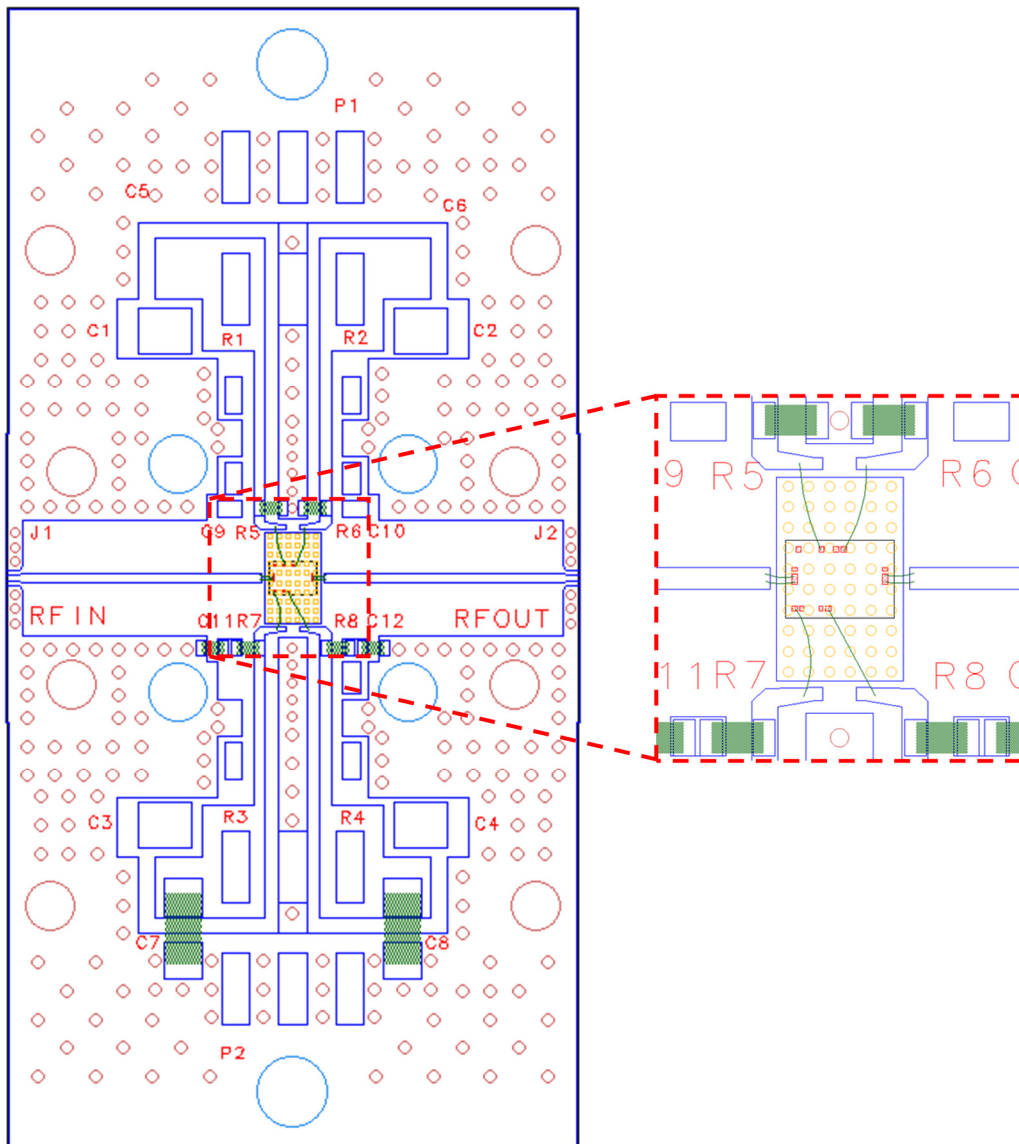
**Bias-up Procedure**

1. Set  $I_D$  limit to 400 mA,  $I_G$  limit to 4.5 mA
2. Set  $V_G$  to -5.0V
3. Set  $V_D$  +25V
4. Adjust  $V_G$  more positive until  $I_{DQ} = 40$  mA.
5. Apply RF signal

**Bias-down Procedure**

1. Turn off RF signal
2. Set  $V_G$  to -5.0V. Ensure  $I_{DQ} \sim 0$ mA
3. Set  $V_D$  to 0V
4. Turn off  $V_D$  supply
5. Turn off  $V_G$  supply

### Evaluation Board

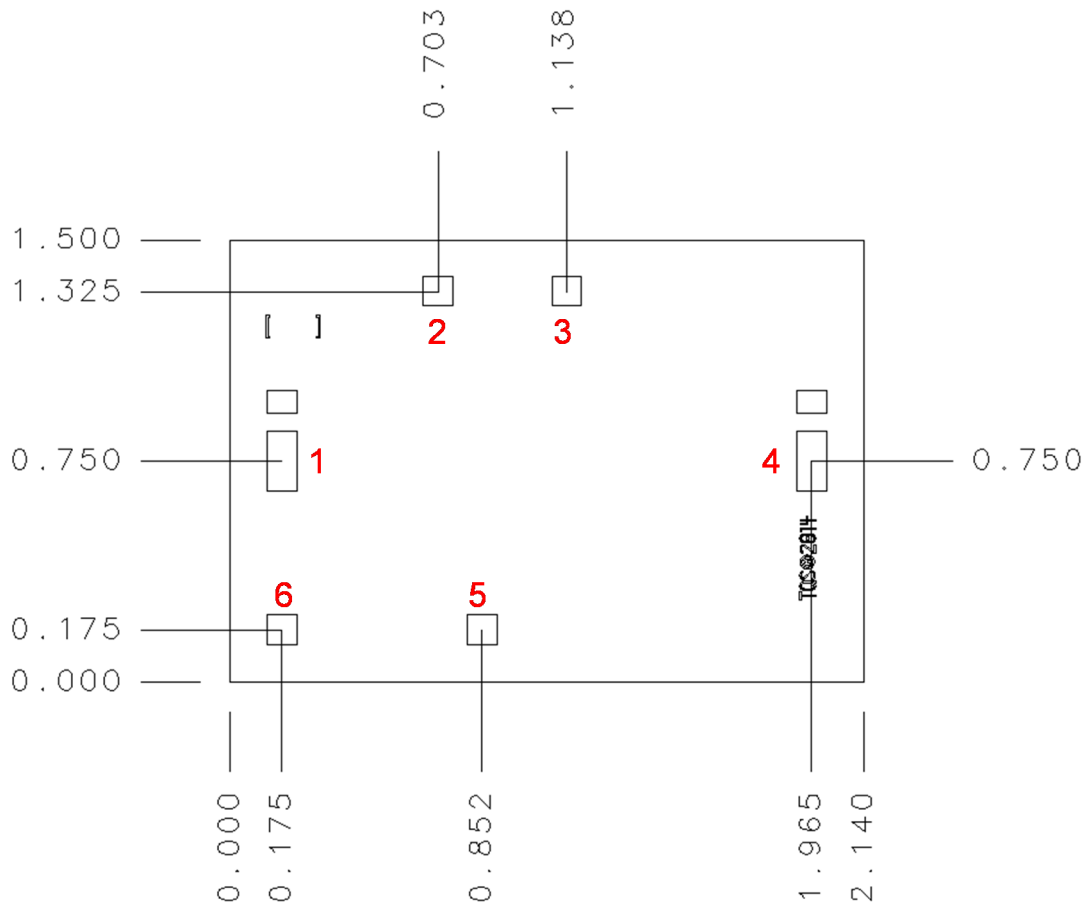


### Bill of Materials

Ref. Designation	Value	Description	Manufacturer	Part Number
R7 – R8	5.1 Ohm	Res, 0402, 5% ROHS	Various	
C7 – C8	1.0 uF	Cap, 1206, 16V, 20%, X5R	Various	
C9 – C12	0.01 uF	Cap, 0402, 50V, 10%, X7R	Various	

RF Layer is 0.008" thick Rogers Corp. RO4003C,  $\epsilon_r = 3.38$ . Metal layers are 0.5 oz. copper. The microstrip line at the connector interface is optimized for the Southwest Microwave end launch connector 1092-01A-5. Die attach is accomplished with conductive epoxy. The PCB land pattern has been developed to accommodate bond wire and die tolerances.

### Mechanical Drawing & Bond Pad Description



Unit: millimeters  
 Thickness: 0.10  
 Die x, y size tolerance: +/- 0.050  
 Chip edge to bond pad dimensions are shown to center of pad  
 Ground is backside of die

Bond Pad	Symbol	Description	Pad Size (um x um)
1	RF In	RF Input; matched to 50 ohms; AC coupled.	100 x 200
2	V <sub>D1</sub>	Drain voltage, first stage.	100 x 100
3	V <sub>D2</sub>	Drain voltage, second stage.	100 x 100
4	RF Out	RF Output; matched to 50 ohms; AC coupled.	100 x 200
5	V <sub>G2</sub>	Gate voltage, second stage.	100 x 100
6	V <sub>G1</sub>	Gate voltage, first stage.	100 x 100

## Assembly Notes

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment (i.e. epoxy) can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.

Reflow process assembly notes:

- Use AuSn (80/20) solder and limit exposure to temperatures above 300°C to 3-4 minutes, maximum.
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- Do not use any kind of flux.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Devices with small pad sizes should be bonded with 0.0007-inch wire.